

# ARGOS matrix 200 / 300

automated scratch/dig inspection

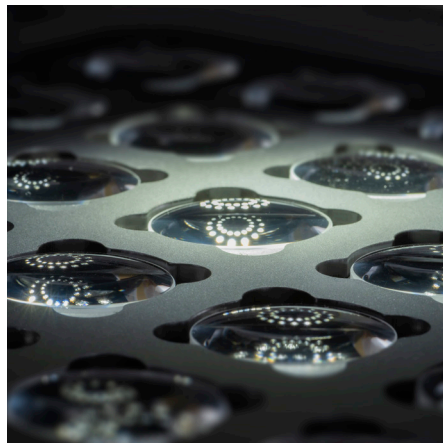
DI OPTIC  
thinking your optics



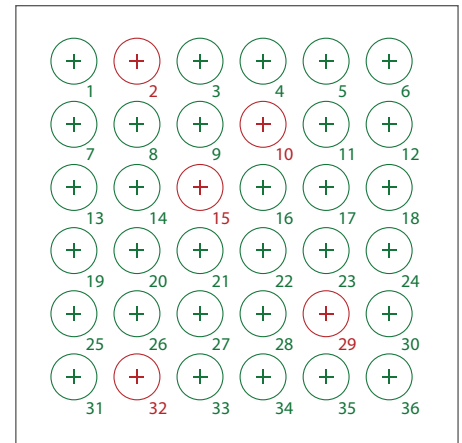
- FULLY AUTOMATED SURFACE INSPECTION
- VERSATILE FROM MICRO-OPTICS TO WAFERS
- OBJECTIVE AND REPRODUCIBLE



Automated stitching of large parts



Serial inspection of many parts on a tray



Clear pass/fail decision and detailed reports

## BENEFITS

**Large flexibility:** any shape from aspheric micro lenses to 12" wafers can be inspected.

**Automated serial inspection without user interaction** reduces cost and improves process quality.

**Objective test results with clear decisions and detailed information** on relevant defects and statistics.

## FUNCTIONALITY

ARGOS matrix is equipped with a high-resolution camera and a switchable dark-field illumination. Images with different lighting configurations are fused for reliable defect detection with high repeatability. A precision

12" stage allows inspection of large numbers of parts in a tray. Our stitching mode allows inspection of large parts-flat or curved. PDF test reports with clear decision and detailed information are automatically created.

## SPECIFICATIONS

ARGOS measurement head	ARGOS matrix S	ARGOS matrix M	ARGOS matrix L
Smallest ISO 10110-7 size grade	0.004 (digs), 0.0025 (scratches)	0.0063 (digs), 0.004 (scratches)	0.01 (digs), 0.0063 (scratches)
Smallest visible defects*	< 1 µm	< 2 µm	< 3 µm
Reproducibility of the size measurement*	< 1.5 µm	< 3 µm	< 4.5 µm
Inspection example*: 8" wafer	12 min	4 min	2 min
Inspection example*: Lens, D=30mm, curvature R=30mm	4 min	2 min	15 s
Maximum inspection area / System size (LxWxH)	<b>ARGOS matrix 200:</b> 205x205 mm / 645x520x700 mm <b>ARGOS matrix 300:</b> 305x305 mm / 845x720x700 mm		
Surface materials	Polished, uncoated or coated surfaces with optical quality, e.g. glass, semiconductors, metals, plastics, crystals, other surface types on request.		

\*for details see technical specification document